PROCEDURE FOR MEASURING TRACE QUANTITIES OF S_2F_{10} , S_2OF_{10} , AND $S_2O_2F_{10}$ IN SF₆ USING A GAS CHROMATOGRAPH-MASS SPECTROMETER

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INTRODUCTION

The compounds S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ are formed by decomposition of gaseous sulfur hexafluoride (SF₆) in electrical discharges.^{1,2} The species S_2F_{10} is known to be highly toxic to humans,³ and there is recent evidence that $S_2O_2F_{10}$ may also be very toxic.⁴ There is, therefore, an interest in having analytical methods to detect these compounds in compressed SF₆ at trace levels down to 10 parts in 10⁹ by volume (10 ppb_v). Two chromatographic methods have been used to detect these compounds at the 10 ppb_v level or lower. The first method developed by Sauers and coworkers⁵ is based on a cryogenic enrichment procedure first proposed by Janssen,⁶ and uses a gas chromatograph with an electron-capture detector. The second method, which is the focus of the present work, utilizes a gas chromatograph-mass spectrometer (GC/MS) with a thermal-chemical converter.⁷

The purposes of the present work are: 1) to define a procedure for using the GC/MS method to make fast, reliable measurement of trace S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ in pressurized SF_6 ; 2) to discuss the major sources of error that can be encountered in using the method; and 3) to discuss the factors that limit the sensitivity such as interference from other compounds.

MEASUREMENT SYSTEM

The GC/MS measurement system, shown diagrammatically in Fig. 1, has previously been described in detail by Olthoff and coworkers.⁷ The gas chromatograph connects to a quadrupole mass spectrometer through a jet separator that is heated to a temperature of about 180 °C. A significant fraction of the S_2F_{10} that enters the jet separator tube from the GC column is converted to SOF₂ by a surface-catalyzed reaction with H₂O adsorbed on the walls of the separator. Peaks therefore appear in

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Figure 1. Diagram of the gas chromatograph-mass spectrometer system.

Table 1. Mass-to-charge ratios of ions in atomic units (u) selected for observing S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ and typical GC-column retention times.

	S2F10	S ₂ OF ₁₀	$S_2O_2F_{10}$	
Ions observed (m/z)	(86,67,48)	(86,48)	(121,102,86,67)	
Column retention time (min)	4.48	3.99	5.72	

the "single-ion" chromatograms at mass-to-charge ratios (m/z) of 48, 67, and 86 u (characteristic of the SOF₂ mass spectrum) at the time that S_2F_{10} elutes from the column. The conversion to SOF₂ avoids the interferring effects of SF₆ on the S_2F_{10} signal and enormously enhances the sensitivity of detection. The interference of SF₆ is a consequence of the fact that it has a mass spectrum identical to that of S_2F_{10} at the standard 70 eV electron-impact ionization energy.⁸ This method allows S_2F_{10} to be detected in SF₆ down to the 1 ppb_v level.

It is not necessary for the species S_2OF_{10} and $S_2O_2F_{10}$ to undergo a chemical conversion in the jet seperator in order to detect them with high sensitivity, because the predominant ions in their mass spectra are different from those in the SF₆ mass spectrum. The observed GC-column retention times for S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ and the m/z values of the ions that were used to detect these compounds are given in Table 1.

The retention times given in Table 1 apply to a 7.3 m Chromosorb WAW column[‡] operated at room temperature (20-23 °C). No attempt has yet been made to determine the lowest concentrations of S_2OF_{10} and $S_2O_2F_{10}$ that can be detected with this system.

ANALYTICAL PROCEDURE

A quantitative analysis of SF₆ gas using the GC/MS method to determine the concentrations of S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ at trace levels is most accurately performed by making immediate comparisons with reference gas samples that contain known concentrations of these compounds. Using the programmable features of the GC/MS, it is possible to make a sequence of sample injections that give responses which appear

⁴Certain commercial equipment, instruments, or materials are identified in this paper to specify adequately the experimental procedure. Such identification does not imply recommendation or endorsement by the National Institute of Standards and Technology, nor does it imply that the materials or equipment identified are necessarily the best available for the purpose.



Figure 2. Single-ion chromatogram for m/z = 86 u showing responses from a sequence of four 1.0 ml injections: two unknowns and two references containing the indicated amount of S_2F_{10} in 300 kPa SF₆.

on one single-ion chromatogram as shown in Fig. 2. In obtaining the chromatogram displayed in Fig. 2, the mass spectrometer was not operated for the first three minutes following the injection of a sample into the GC column. This is the time during which most of the SF_6 elutes from the column. Deactivation of the mass spectrometer during this time reduces the background and inhibits exposure of the detector to the large ion flux associated with SF_6 .

In following this procedure, it is desirable to bracket one or more injections from the unknown sample with at least two injections from a reference containing a known concentration of the species of interest. In this way, it is possible to eliminate errors due to drift in the GC/MS response such as associated with GC-column conditioning effects, changes in the jet separator surface composition, and variations in the electron-impact source conditions. It is also desirable to use the same injection size (quantity of gas) for both the reference and the unknown and to adjust the concentration of the reference to give a response (peak height) that closely matches that of the unknown. These precautions reduce the errors associated with nonlinearities in the response which tend to be more of a problem with S_2F_{10} than with the other species.⁷ The results of analysis for S_2F_{10} content shown in Fig. 2 were obtained using a 1.0 ml \times 300 kPa injection size. The unknown concentration is determined from the ratio of the average responses from the unknown and reference injections based on either peak heights or areas under the peaks. If there are no interference effects associated with other compounds or with previous injections, the area and peak-height determinations should yield the same result to within the normal statistical variability which will tend to increase as the response (concentration) decreases. Interference from preceding injections can usually be eliminated by appropriate adjustment of the sample monitoring times (MS on) in the injection sequence, which is 3.0 min for the case shown in Fig. 2. Before setting up the injection sequence, it is desirable to make is single "long-time" chromatogram from the unknown sample to determine the possible presence of other peaks at times longer than that for the species of interest.



RETENTION TIME (minutes)

Figure 3. Single-ion chromatograms at m/z = 86 u that show the effect of SOF₂ on the detection of 20 ppb₀ S₂F₁₀ in 200 kPa SF₆. Shown are the concentrations of SOF₂ that were present and the peak for S₂F₁₀ that appears at a retention time of about 4.8 min.

SOURCES OF ERROR

Interference Effects

When the GC column is operated under "normal conditions" at a temperature of 20 °C and a helium carrier gas flow rate of 20 to 30 ml/min at atmospheric pressure (100 kPa), the compounds S2F10, S2OF10, and S2O2F10 are sufficiently well separated in time that they do not interfere with each other. It is thus possible to observe all three species on a single chromatogram for the common ion at m/z = 86 u (see Table 1). The compound SOF₂ has a retention time of less than 2.4 min under the conditions that give the results listed in Table 1; therefore it is sufficiently well separated from the compounds of interest that it does not ordinarily cause significant interference. On the other hand, if its concentration greatly exceeds that of the compounds of interest, particularly S₂F₁₀, it can have the effect of increasing the background level enough to reduce the detection sensitivity. This is illustrated by the results displayed in Fig. 3. Shown in this figure are the responses for samples that all contain 20 ppb_y S_2F_{10} and differing amounts of SOF2 from 0 to 500 parts in 10⁶ by volume (ppm,). It is seen that the S2F10 detection sensitivity is reduced to about 20 ppb, when the SOF2 concentration reaches the 500 ppm, level. Over this range of SOF2 concentrations, the lowest concentration of S_2F_{10} in ppb, that can be detected is estimated from the data to be $(2.0 + 3.6 \times 10^{-2} [SOF_2])$ where $[SOF_2]$ is in ppm_e.

Of the contaminants that are often present in commercial SF₆, it was found that the compound CCl₂F₂ can be a source of interference in the detection of S₂F₁₀ under some conditions. This is because it has a retention time that is only 0.10 min shorter than that for S₂F₁₀. In most cases it is possible to distinguish CCl₂F₂ from the SOF₂ formed from S₂F₁₀ by examination of the mass spectrum for the feature attributed to S₂F₁₀. The relative abundances of the major ions that appear in the mass spectra of both SOF₂ and CCl₂F₂ for $m/z \ge 50$ u are given in Table 2. Interference from CCl₂F₂

Abundances				Abundances	
m/z (u)	SOF ₂	CCl ₂ F ₂	m/z (u)	SOF ₂	CCl ₂ F ₂
50	0.012	0.118	70	0.017	0.002
51	0.036	0.001	85	0.000	1.000
66	0.000	0.036	86	0.556	0.010
67	1.000	0.000	87	0.005	0.326
68	0.010	0.012	101	0.000	0.087
69	0.046	0.000	103	0.000	0.057

Table 2. Relative abundances of ions in the mass spectra of SOF₂ and CCl₂F₂ for $m/z \ge 50$ u.



Figure 4. Single-ion chromatograms at m/z = 86 u from two different SF₆ gas samples containing either CCl₂F₂ or S₂F₁₀ before and after heating at 250 °C for 30 min.

is only a problem if the mass spectrometer is slightly detuned to enhance the detection sensitivity at m/z = 86 u. Under conditions where the mass resolution is insufficient to allow complete separation of the adjacent ions at m/z = 85, 86, 87 u, the CCl_2F_2 interference can become significant. However, even with poor mass resolution, CCl_2F_2 can usually be distinguished from SOF_2 at m/z = 67 u.

Independent of how the mass spectrometer is operated, it is possible to perform a pyrolysis test to confirm that the observed peak in the chromatogram is due to S_2F_{10} . This is illustrated by the chromatograms shown in Fig. 4 that were obtained from two different SF_6 gas samples, one containing CCl_2F_2 at an unknown trace level and one containing 250 ppb_v S_2F_{10} . Indicated in this figure are the chromatograms that were obtained before and after these samples were heated for 30 min at a temperature of 250 °C in a 150 cm³ stainless-steel cylinder. It is seen that the CCl_2F_2 feature remains unchanged after heating, whereas the S_2F_{10} disappears, presumably by the same process that converts it into SOF_2 in the heated jet separator of the GC/MS. The compound $S_2O_2F_{10}$ is also thermally unstable at 250 °C and will disappear from the sample after heating as illustrated by the results shown in Fig. 5. It is also seen from this figure that $S_2O_1F_{10}$ is unaffected by the heating. This compound is relatively more stable than either $S_2O_2F_{10}$ or S_2F_{10} , and is frequently observed to be a contaminant in commercial SF_6 .



Figure 5. Single-ion chromatograms at m/z = 86 u before and after heating an SF₆ gas sample containing trace amounts of CCl₂F₂, S₂OF₁₀, and S₂O₂F₁₀.

Reference Sample Preparation

The most significant source of error in using a GC/MS to measure the content of S_2F_{10} , S_2OF_{10} , and $S_2O_2F_{10}$ in SF₆ is likely to occur in the process of preparing reference samples. The decomposition of S_2F_{10} and $S_2O_2F_{10}$ that occurs at temperatures above 180 °C also occurs at room temperature at a slower rate. This decomposition process can introduce errors in determining and controlling the concentration of S_2F_{10} or $S_2O_2F_{10}$ in a reference sample.

The usual procedure in preparing a reference sample is to inject a known quantity of the trace gas of interest into a sample cylinder under vacuum and then introduce the SF_6 to the desired pressure. In the process of doing this, the trace gas is usually retained initially in tube of relatively small diameter. In the case of S_2F_{10} , some of the gas will decompose during this retention time as illustrated by the chromatogram shown in Fig. 6. The data in this figure correspond to a sequence of injections made after pure S2F10 was introduced into a 0.6 cm diameter stainless-steel tube under vacuum. It can be seen that a significant decay of the sample occurs in a matter of minutes. There are two precautions that can be taken to minimize the error due to S_2F_{10} decay during sample preparation. The first, is to remove as much H₂O as possible from the surfaces of the sample cylinder and associated tubing, either by direct heating or by flushing with a gas that readily hydrolyzes such as SF4. The second is to minimize the time that the sample container is under vacuum by introducing the diluent gas (SF₆) immediately after the S_2F_{10} is injected into the system. Generally it is better to start by preparing a sample that contains a relatively high concentration of $S_2 F_{10}$ (≥ 1000 ppm_e) and then use successive dilutions with SF_6 to reduce the concentration down to the desired level.

It has been found⁷ that the rate of S_2F_{10} decomposition in a reference sample increases with decreasing S_2F_{10} concentration, total gas pressure, and sample cylinder size. It also increases with increasing temperature and water vapor content. These factors must be considered in maintaining reference samples. To avoid problems of sample decay, it is advisable to prepare a new reference each time that an analysis is to be performed.

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DISCUSSION

L. NIEMEYER: I understand you have a couple of decay channels for $S_2O_2F_{10}$ and one of them is thermal. We know how thermal decay of S_2F_{10} works. Are you able to state how it would work for $S_2O_2F_{10}$ - do you know the appropriate binding energies that would need to be overcome thermally to decompose it?

R. J. VAN BRUNT: Unfortunately I do not know the answer to that question because that compound has not been studied very thoroughly. There is much less known about this compound than S_2F_{10} and we are not aware of any published data on thermal decay of $S_2O_2F_{10}$. We now have evidence that $S_2O_2F_{10}$ spontaneously decomposes at a low rate at room temperature (300 K). From our preliminary tests, it appears that one of the decomposition products is SO_2F_2 . At the present time, for example, we know nothing about the mechanism responsible for the decomposition whether it is a gas-phase or a surface reaction.

I. SAUERS: I would like to point out that we also observed the thermal instability and decay of $S_2O_2F_{10}$ to be similar to the situation with S_2F_{10} . Also, from preliminary work done by Dr. Guy Griffin at Oak Ridge National Laboratory on the toxicity of $S_2O_2F_{10}$ using cell culture bioassays, it appears that the toxicity of $S_2O_2F_{10}$ approaches that of S_2F_{10} , i.e. it is less toxic than S_2F_{10} but more toxic than the other SF₆ by-products studied (SOF₂, SO₂F₂, SF₄, SO₂ and HF). No other toxicity data are currently available in the literature.

S. W. ROWE: In switchgear insulating spacers will constitute a quasi-permanent source of humidity even if a filter is fitted. This is because the humidity must diffuse through the gas to reach the filter and a local high humidity zone will probably build up at the spacergas interface. What sort of reactions with S_2F_{10} and S_2OF_{10} would be expected under these conditions? Would decay be promoted with respect to an "all-metal" situation? Would any catalytic type reactions be expected with the diverse components of the spacer?

R. J. VAN BRUNT: We have evidence that the rate of S_2F_{10} decomposition in SF₆ at room temperature (300 K) is increased when cast epoxy materials are introduced. Presently there is no evidence that the mechanism of S_2F_{10} decomposition on epoxy surfaces is any different from that which occurs on metal surfaces. The enhancement in S_2F_{10} decomposition rate when epoxy is present may simply be due to the fact epoxy is more efficient than metals in adsorbing H₂O.

H. MORRISON: The probable source of CCl_2F_2 (Freon 12) in commercial SF₆ is a leak from the cooling compressors used by the manufacturers in the production of SF₆. As well, CCl_2F_2 has been used by some GIS manufacturers and some utilities as a tracer to test for pressure leaks.

R. J. VAN BRUNT: It should be noted that CCl_2F_2 generally appears at trace levels (less than 200 ppb) in nearly all commercial-grade SF₆ that we have analyzed.

J. CASTONGUAY: You did try to condition the internal surface of your small introduction tube to limit the surface conversion of S_2F_{10} . Was this effective?

R. J. VAN BRUNT: We have found that predrying of the sample cylinder, either by heating under vacuum or by introducing SF₄ that readily reacts with H₂O to form HF and SOF₂, helps to reduce the rate of S_2F_{10} decomposition in gas mixtures that are subsequently introduced into that cylinder. We would recommend the heating method for drying. The formation of HF from SF₄ could have undesirable side effects.

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